IN THE CLAIMS

This listing of claims replaces all prior listings:

1. (Currently Amended) <u>A Method method</u> of manufacturing a diffusing reflector comprising the processes of:

preparing a substrate;

forming a first resin film having photosensitivity on said substrate;

providing <u>a</u> gathering of pillar-shaped bodies isolated from each other through patterning of said resin film with photolithography;

deforming gently said pillar-shaped bodies through a reflow;

forming an uneven surface layer having the maximum inclination angle of under 12⁰ by coating with a thin layer of a second resin said gently deformed pillar-shaped bodies and;

covering with the second resin open flat spaces located between said isolated pillarshaped bodies to form one concave gap between two adjacent isolated pillar-shaped bodies so that upper end portions of said two adjacent isolated pillar-shaped bodies are higher than a lower end portion of said one concave gap in the thickness direction of the diffusing reflector, thereby minimizing an occurrence of a flat surface area on said substrate; and

forming a metal film on said uneven surface layer,

wherein,

said first resin film is patterned by straight connected lines that form a continuous polygonal pattern, said straight lines providing a gap between thereby formed polygonal pillar-shaped bodies, and

said gap having a size equal to about a minimum resolution of said photolithography.

- 2. (Currently Amended) The Method method of manufacturing a diffusing reflector as claimed in claim 1, wherein said maximum inclination angle is about 10⁰.
 - 3. (Cancelled)

Response to December 14, 2007 Final Office Action Application No. 09/957,422 Page 3

- 4. (Currently Amended) <u>The Method method</u> of manufacturing a diffusing reflector as claimed in claim 1, wherein said reflow process is a heat treatment under the temperature of about 220°C.
- 5. (Currently Amended) <u>The Method method</u> of manufacturing a diffusing reflector as claimed in claim 1, wherein gathering of polygonal pillar-shaped bodies isolated <u>from each</u> other by the divided patterning of said first resin film by said photolithography is provided.
 - 6. (Cancelled)